

		Garage Mout	DB	Time stamp
L	Hits	Search Text		
Number		the stand or methanol I same	USPAT;	2002/08/05
1	550	(isopropyl or ethanol or methanol) same	EPO; JPO;	10:58
		(HF or hydrofluoric) and ("silicon oxide"	IBM TDB	
		or "SiO.sub.2")	USPAT;	2002/08/05
2	13968	MEMS or "micro electro mechanical system"	EPO; JPO;	10:19
	Į		IBM TDB	10.13
			USPAT;	2002/08/05
3	20	((isopropyl or ethanol or methanol) same	EPO; JPO;	10:24
		(HF or hydrofluoric) and ("silicon oxide"		10.24
		or "SiO.sub.2")) and (MEMS or "micro	IBM_TDB	
		electro mechanical system")	*************	2002/08/05
4	522	((isopropy) or ethanol or methanol) same	USPAT;	
		(WE or hydrofluoric) and ("silicon oxide"	EPO; JPO;	10:26
		or "SiO sub 2")) and (etch\$4 or remov\$4)	IBM_TDB	0000/00/05
5	168	(//isopropy) or ethanol or methanol)	USPAT;	2002/08/05
	100	same (HF or hydrofluoric) and ("sillcon	EPO; JPO;	10:26
		oxide" or "SiO.sub.2")) and (etch\$4 or	IBM_TDB	
		removs4)) and 438/\$.ccls.		
6	585		USPAT;	2002/08/05
	363	(HF or hydrofluoric) and ("silicon oxide"	EPO; JPO;	10:58
		or "SiO. sub.2" or PSG or BPSG or TEOS)	IBM TDB	ì
	921		USPAT;	2002/08/05
7	921	system") and ("silicon oxide" or	EPO; JPO;	10:58
	1	"SiO.sub.2" or PSG or BPSG or TEOS)	IBM TDB	
	1005		USPAT;	2002/08/05
8	1235	(HF or hydrofluoric) same (vapor or	EPO; JPO;	11:04
	ļ		IBM TDB	
	1	water) ((MEMS or "micro electro mechanical	USPAT;	2002/08/05
9	16	system") and ("silicon oxide" or	EPO; JPO;	10:59
		system") and ("Silicon oxide of "silicon oxide" oxide of "silicon oxide of "silicon oxide of "silicon oxide" oxide	IBM TDB	
		TESTOLSODIZE OF FOO OF DECO OF THEFT		
		([] SOD [ODVI OI ECHANOL OI WE SHALL ,		
		(HF or hydrofluoric) same (vapor or	1	
		water))	USPAT;	2002/08/05
10	178	(isopropyl or ethanol or methanol) same	EPO; JPO;	11:05
	1	(HF or hydrofluoric) same vapor	IBM TDB	11.00
	1		TRM IND	